

ATTORNEY DOCKET NO.: JC-7109-CIP

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of  
SHAO-CHUNG HU; TENG-CHUN  
TSAI; CHIA-LIN HSU; AND YUNG-  
TSUNG WEI

Group Art Unit: 2813

Examiner: N / A

Serial No.: 10/603,924

Filed: June 24, 2003

For: POST-CMP REMOVAL OF  
SURFACE CONTAMINANTS FROM  
SILICON WAFER

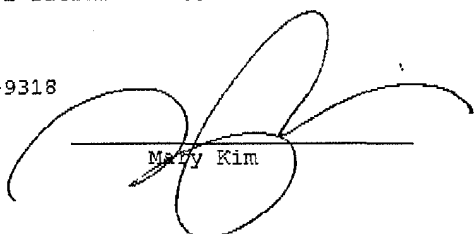
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UNDER 37 CFR § 1.6; MPEP 502.01

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EXAMINER : N/A  
USPTO ART UNIT : 2813  
FACSIMILE NO.: 703-872-9318

on October 21, 2003  
Mary Kim**PRELIMINARY AMENDMENT**

Dear Sir:

In connection with the above-referenced patent application,  
please withdraw the Preliminary Amendment filed on June 24, 2003  
and enter the following Preliminary Amendments: